## UNUSUALLY LARGE DESHIELDING OF <sup>29</sup>Si IN 7-SILANORBORNADIENES AND RELATED COMPOUNDS<sup>1)</sup>

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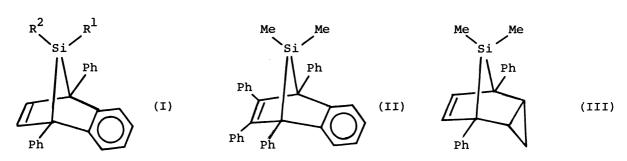
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Bridge silicon atoms in [2.2.1] bicyclic systems display unusually large deshielding in  $^{29}{\rm Si}$  NMR. An explanation is given to account for the phenomena.

Recently we have prepared several derivatives of the so far elusive 2,3-benzo-1,4-diphenyl-7-silanorbornadienes (I), which serve as efficient silylene generators. The reaction of I is interesting in reference to the silylene chemistry and in fact we have found a novel silylene to disilene rearrangement in the reaction of Me<sub>3</sub>SiMe<sub>2</sub>SiMeSi:. However, these compounds are also interesting in the study of the structures, since 7-heteroatom-norbornadienes display sometimes unusual properties. In this paper, we will describe the extraordinary deshielding of <sup>29</sup>Si in 7-silanorbornadienes and related compounds.

Table 1 lists  $^{29}$ Si NMR data for five derivatives of 2,3-benzo-1,4-diphenyl-7-silanorbornadiene (I) and three other compounds, 2,3-benzo-1,4,5,6-tetraphenyl-7,7-dimethyl-7-silanorbornadiene (II), $^{3)}$  1,5-diphenyl-8,8-dimethyl-8-silatricyclo-[3.2.1.0 $^{2,4}$ ]oct-6-ene (III), $^{4)}$  and 3,3,10,10-tetramethyl-3,10-disilatricyclo-[5.2.1.0 $^{2,6}$ ]deca-4,8-diene (IV).



a: 
$$R^1 = R^2 = Me$$
  
b:  $R^1 = Me$ ;  $R^2 = SiMe_3$   
c:  $R^1 = Me$ ;  $R^2 = SiMe_2Ph$   
d:  $R^1 = Me$ ;  $R^2 = SiMe_2SiMe_3$   
e:  $R^1 = R^2 = SiMe_3$ 

(IV)

Compound	(Ia)	(Ib)	(Ic)	(Id)	(Ie)	(11)	(III)	(IV)
bridge Si	76.9	82.5	80.2	85.7	97.7	67.7	58.5	40.8
other Si		-19.3	-22.1	-47.6 -15.5				17.8

Table 1.  $^{29}$ Si NMR Chemical Shifts of Some Cage Compounds  $(\delta, \text{ ppm relative to Me}_{_{A}}\text{Si})^{a, b}$ 

The preparation of IV, a dimer of 1,1-dimethyl-1-silacyclopentadiene (V), requires some comments. Recently, two groups have independently succeeded in the preparation of C-unsubstituted siloles including V,<sup>5)</sup> which is very reactive giving a dimer (IV) on standing. At almost the same time, we also have prepared V and IV by an entirely different method. Being no <sup>29</sup>Si NMR data given in the preceding papers, we used our own sample for the <sup>29</sup>Si NMR measurement. Taking this opportunity, we describe our method of preparation briefly.

Bis(2-lithioethenyl)dimethylsilane (VI)<sup>6)</sup> was the precursor to V. Copper iodide-catalyzed coupling of VI gave V, the formation of which was confirmed by GC-MS. However, V could not be isolated and after work-up, only IV was obtained in low yield. Physical data of IV agreed well with those reported.<sup>5)</sup>

$$Me_2Si$$
 $Li$ 
 $CuI$ 
 $Me_2Si$ 
 $Me_2Si$ 

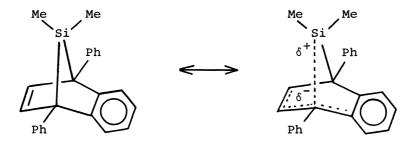
It is apparent that 7-silabicyclo[2.2.1]heptadienes and related compounds display a  $^{29}$ Si resonance at very low field. Rather surprisingly, these resonances appear at far lower field than  ${\rm sp}^2$ -hybridized silicon atoms of recently prepared disilene (63.6 ppm) $^{7)}$  and silene (54.3 ppm) $^{8)}$  derivatives. Indeed, Ie has the most deshielded  $^{29}$ Si resonance except for an iron cluster compound with a dimethylsilandiyl bridge. $^{9)}$ 

<sup>&</sup>lt;sup>a</sup> In CDCl<sub>3</sub>. <sup>b</sup> Spectra were taken with a JEOL FX-90Q spectrometer.

Such an anomal deshielding for the 7-atoms of similar norbornadiene and norbornene systems has been reported recently on 7-phosphanorbornenes  $^{10,11)}$  and 7-phosphanorbornadiene complexes.  $^{12)}$  The  $^{13}$ C resonances of 7-C atoms of norbornane (38.4), $^{13)}$  norbornene (48.5) and norbornadiene (75.1) also display increasing deshielding for the bridge carbon atoms.  $^{14)}$ 

The angle strain at the 7-atoms may be a factor to the phenomena but should not be regarded as a sole factor to this anomal deshielding, since  $^{29}$ Si resonances of 1,1-dimethyl-1-silacyclopentane  $(16.4)^{13,15}$ ) 1,1-dimethyl-1-silacyclo-2-pentene (17.4),  $^{16}$ ) and 1,1-dimethyl-1-silacyclo-3-pentene  $(16.5)^{16}$ ) do not change the position of the chemical shifts by decreasing the ring size to 1,1-dimethyl-1-silacyclobutane  $(18.4)^{15}$ ) On the contrary, dimethylsilacyclopropanes have  $^{29}$ Si resonances at extremely high field.  $^{17}$ )

An enhanced polarization at the ground state of the molecules seems to be a good reason to this deshielding effect. Such a polarization shown below shoud be associated to  $\sigma-\pi$  conjugation which must be very important in the rigid framework. The importance of  $\sigma-\pi$  conjugation in strained cage systems and in organometallic compounds are well documented. 18)



In this connection, it is worthwhile mentioning that the magnitude of the deshielding effect is in the order of I > II > III > IV. In 2,3-benzo-1,4,5,6-tetra-phenyl-7,7-dimethyl-7-silanorbornadienes (II), the bridge-head phenyl groups are perpendicular to the benzo group and the Si-C(bridge-head)  $\sigma$  bond lies in the nodal plane of the phenyl group. 

Therefore, the degree of  $\pi$  conjugation of the C-Si bond with the  $\pi$  system in II must be smaller than in I. It is interesting to discuss the lesser stability of I than II toward nucleophiles as well as in the thermolysis in terms of the deshielding effect, but it may be wise to wait for the pertinent kinetic data.

Acknowledgment. We thank Toshiba Silicone Co., Ltd. for a gift of chlorosilanes. The work was supported in part by the Mitsubishi Science Foundation.

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(Received December 23, 1982)